

Current Status of Light Sources and Beamlines

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Light Source in 2014

1. Status of UVSOR Accelerators

In the fiscal year 2014, we operated UVSOR-III from June to February, for 36 weeks for users as usual. We had a shutdown period in April and May for about six weeks. This was for a upgrade program on the beam-line BL5U, which included the remodeling of the undulator U5 to an APPLE-II type polarization variable undulator and the re-construction of the photo-electron spectroscopy beam-line, BL5U.

We operated the machine for 34 weeks in the multi-bunch top-up mode, in which the beam current was kept at 300 mA with the top-up injection, and 2 weeks in the single-bunch mode, in which the machine is operated in single-bunch top-up mode with the beam current of 50 mA. The monthly statistics of the operation time and the integrated beam current are shown in Fig. 1.

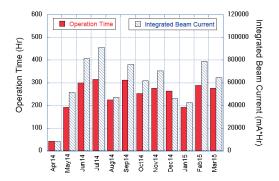


Fig. 1. Monthly statistics in FY2014.

The weekly operation schedule is as follows. On Monday, from 9 am to 9 pm, the machine is operated for machine studies. On Tuesday and Wednesday, from 9 am to 9 pm, the machine is operated for users. From Thursday 9am to Friday 9pm, the machine is operated for 36 hours continuously for users. Thus, the beam time for users in a week is 60 hours. Usually, we have a few weeks dedicated for machine study, however, in the last year, we did not have them to keep the beam time for users against the rather long shutdowns. This year we could have 5 weeks, in the middle of August, in November, just before and after the New Year vacation and the last week in FY2014. The machine study week on November is mainly dedicated for the recovery of the accelerators after the annual planned power outage.

In this fiscal year, we had a few machine troubles on the electron gun, on the RF signal generator and on the water load of the main RF cavity. However, fortunately, in all cases the beam time for users could be secured by extending the operation time in the same week.

More serious trouble happened during the shutdown period in April. During a machine

conditioning run, we observed a sudden vacuum pressure rise at the 3rd harmonic cavity, which is used for stabilizing the beam and extending the beam lifetime routinely. This happing will be described in detail in the next section.

2. Improvements and Developments

Vacuum Pressure Rise in the 3rd harmonic Cavity In April 2014, we observed pressure rises in the 3rd harmonic RF accelerating cavity during the vacuum conditioning run. We carefully surveyed vacuum leakage on the cavity using a He leakage detector, however we could not find any suspicious part. Then, we checked the water cooling channels with the same detector one by one. Soon, we found some leakage from the water channel for one of the electrode. Since we had only a few weeks before starting the users operation, we tried to repair it using sealant. It was successful after a few trials. Then, we baked the cavity and the neighboring sections. We started the vacuum conditioning run just one week before the start of the users operation. Finally, we could start the users operation as scheduled. After one year operation, the vacuum pressure has been low enough to continue the operation. For the complete repair, we have constructed a new part for the electrode.

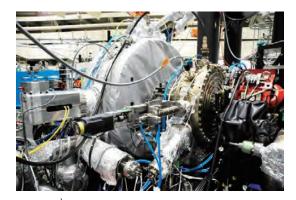


Fig. 2. 3rd Harmonic Cavity.

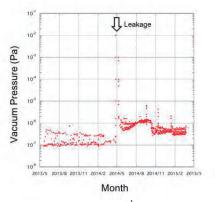


Fig. 3. Pressure History at the 3rd Harmonic Cavity.

Reconstruction of BL5U Polarization Variable Undulator

In March 2014, we remodeled the old variable polarization undulator U5. The magnetic configuration was changed to the APPLE-II one with a shorter period length, 60 mm, as utlizing the present mechanical frame. The field measurement was carried out in the storage ring. The vacuum chamber was also replaced. The new undulator was successfully commissioned and the synchrotron radiation has been being used for conditioning of the new photoelectron spectroscopy beam-line, BL5U.

Beam Injection with Pulse Quadrupole Magnets

A novel injection scheme using a pulsed sextupole magnet has been being developed[1]. Previously the sextupole magnet was installed at one of the kicker magnet by removing it temporally and replacing with the sextupole magnet every time when we carried out the machine study for the device. During the shutdown in April, a new dedicated vacuum duct for the pulsed sextupole magnet was installed just downstream of the undulator U5. With the new location, we have succeeded in injecting the beam with the efficiency of around 20 % during the first trial. We are going to improve the efficiency higher than 50% for users operation.

Light Source Developments and Beam Physics Studies

We continue the efforts to develop coherent light sources including free electron lasers, coherent harmonic generation and coherent synchrotron radiation at the new source development station BL1U. This year, we have been improving the laser transport system to stabilize the coherent radiation intensity in cooperation with Laser Research Center at IMS and Nagoya University. Also, we are reconstructing the optical cavity for the resonator free electron laser. A gamma-ray production has been being tried in cooperation with Kyoto University for imaging study [2]. An irradiation experiment using polarized ultraviolet has been being carried out in corporation with Tokyo University of Science.

In the beam physics study, we have succeeded in observing micro-bunching structure in the electron bunches circulating in the UVSOR storage ring during the micro-bunching instability for the first time in the world [3]. The key to the success was a novel ultrafast THz detector developed at Kurlsruhe Institute of Technology. The observed results could be explained by a model developed by Lille University.

Electron gun developments towards future quantum beam sources

Electron guns of two types are being developed. One is a spin polarized electron gun. This is being developed towards inverse photo-electron spectroscopy in collaboration with Nagoya University. In FY2014, we have succeeded in measuring the temporal response of the photocathode in the picosecond range [4].

Another electron gun is a superconducting photocathode one towards future high repetition rate free electron laser. At UVSOR, the photocathode part is mainly being developed, in collaboration with KEK. A transparent and superconducting photocathode was successfully demonstrated [5].

References

- [1] N. Yamamoto et al., in these reports
- [2] H. Zen et al., in these reports
- [3] E. Roussel *et al.*, in these reports
- [4] T. Inagaki *et al.*, in these reports
- [5] T. Konomi et al., in these reports

Masahiro KATOH (UVSOR Facility)

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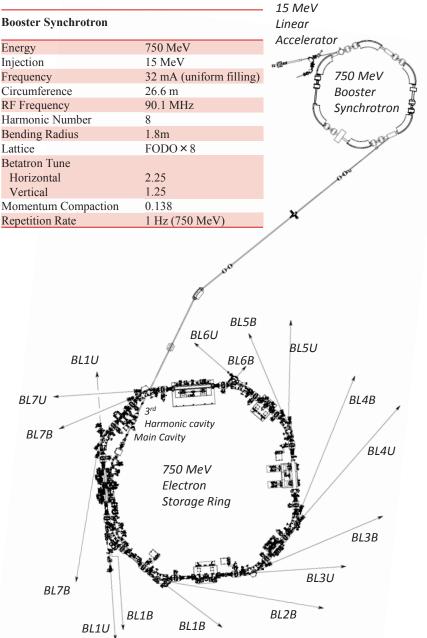
UVSOR Accelerator Complex

Injection Linear Accelerator

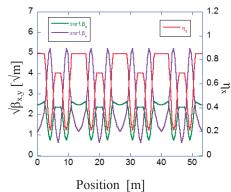
15 MeV
2.5 m
2856 MHz
$2\pi/3$ Traveling Wave
1.8 MW
~1.6 MeV
2.6 Hz

UVSOR-III Storage-Ring

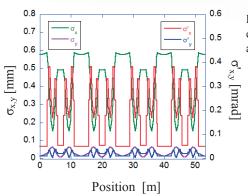
Energy	750 MeV
Injection Energy	750 MeV
Maximum Storage Current	500 mA (multi bunch)
	100 mA (single bunch)
Normal operation current	300 mA (multi bunch)
(Top-up mode)	50 mA (single bunch)
Natural Emittance	17.5 nm-rad
Circumference	53.2 m
RF Frequency	90.1 MHz
Harmonic Number	16
Bending Radius	2.2 m
Lattice	Extended DBA $\times 4$
Straight Section	$(4 \text{ m} \times 4) + (1.5 \text{ m} \times 4)$
RF Voltage	120 kV
Betatron Tune	
Horizontal	3.75
Vertical	3.20
Momentum Compaction	0.030
Natural Chromaticity	
Horizontal	-8.1
Vertical	-7.3
Energy Spread	5.26×10^{-4}
Coupling Ratio	1%
Natural Bunch Length	128 ps



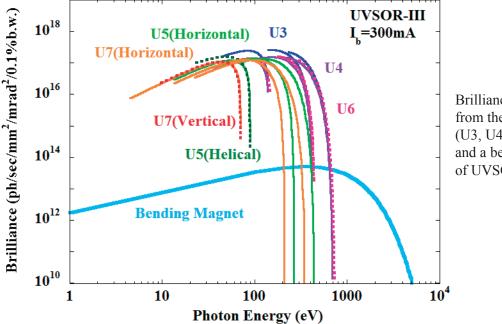
Electron Beam Optics of UVSOR-III Storage Ring



Horizontal/vertical betatron functions and dispersion function



Horizontal/vertical electron beam size and beam divergences



Insertion Device

Brilliance of radiation from the insertion devices (U3, U4, U5, U6 and U7) and a bending magnet of UVSOR-III

U1 Apple-II Undulator /

Optical Klystron	
Number of Periods	10+10
Period length	88 mm
Pole Length	0.968 m + 0.968 m
Pole Gap	24-200 mm
Deflection Parameter	7.36 (Max.
	Horizontal)
	4.93 (Max. Vertical)
	4.06 (Max. Herical)

U3 In-vacuum Undulator

Number of Periods	50
Period length	38 mm
Pole Length	1.9 m
Pole Gap	15-40 mm
Deflection Parameter	2.0-0.24

U4 In-vacuum Undulator

Number of Periods	26
Period length	38 mm
Pole Length	0.99 m
Pole Gap	13-40 mm
Deflection Parameter	2.4-0.19

U5 Apple-II

Variable Polarization Undulator

Number of Periods	38
Period length	60 mm
Pole Length	2.28 m
Pole Gap	24-190 mm
Deflection Parameter	3.4 (Max. Horizontal)
	2.1 (Max. Vertical)
	1.8 (Max. Helical)

U6 In-vacuum Undulator

Number of Periods	26	
Period length	36 mm	
Pole Length	0.94 m	
Pole Gap	13-40 mm	
Deflection Parameter	1.78 - 0.19	

U7 Apple-II

Variable Polarization Undulator

Number of Periods	40
Period length	76 mm
Pole Length	3.04 m
Pole Gap	24-200 mm
Deflection Parameter	5.4 (Max. Horizontal)
	3.6 (Max. Vertical)
	3.0 (Max. Helical)

Bending Magnets

Bending Radius	2.2 m
Critical Energy	425 eV

Beamlines in 2014

Eiji SHIGEMASA UVSOR Facility, Institute for Molecular Science

Among the synchrotron radiation facilities with electron energies of less than 1 GeV, UVSOR is one of the highest-brilliance light sources in the extreme-ultraviolet region, following the successful completion of the storage ring upgrade project (the UVSOR-III project). The natural emittance of the UVSOR-III storage ring is as low as 17.5 nm-rad.

Eight bending magnets and five insertion devices are available as synchrotron light sources at UVSOR. As of 2014 there are a total of fifteen operational beamlines, which are classified into two categories. Twelve of them are the so-called "Open beamlines", which are open to scientists from universities and research institutes belonging to the government, public organizations, private enterprises and also those from foreign countries. The remaining three beamlines are the "In-house beamlines", and are dedicated to the use of research groups within IMS.

There is one soft X-ray station equipped with a double-crystal monochromator, eight extreme ultraviolet and soft X-ray stations with grazing incidence monochromators, three vacuum ultraviolet stations with normal incidence monochromators, two infrared (IR) stations equipped with Fourier-Transform interferometers, and one free electron laser beamline with no monochromator, as shown in the appended table (next page) for all available beamlines at UVSOR in 2014.

BL4U, equipped with a scanning transmission soft X-ray microscope (STXM), which was newly constructed in 2012, has been open to users since June 2013. Many new results have already emerged from this beamline. The performance of BL4U is close to theoretical predictions, except in the photon energy region near the C K-shell ionization threshold $(\sim 300 \text{ eV})$, due to the so-called "carbon contamination" of the optical elements. In 2013, the first mirror was recoated with gold, and the inner wall of the vacuum chamber as well as all parts of the mirror holder were washed with hot water to remove carbon containing elements from the surfaces. Although the photon intensity around 300 eV has tentatively been improved, it has gradually decreased with time. The grating chamber cleaning treatment was repeated during the shutdown term in the spring of 2014. As a result, the photon intensity around 300 eV has greatly been improved, and STXM analyses near the C-K edge have become feasible.

BL2B was reorganized as an open beamline in 2013, which has been conducted as one of the long-term project proposals. As an endstation of BL2B, an experimental setup for angle-resolved photoelectron spectroscopy (ARPES) of inorganic thin films was brought from Chiba University. Commissioning and performance tests were initiated in September 2014. During commissioning, vacuum

pressure rises at the first mirror chamber were frequently observed. A leak was subsequently found in the water cooling system for the first mirror. Although it takes about 20 min. to stabilize the beam position on the entrance slit, it has been decided to continue the operation of BL2B without water cooling.

The construction of a new soft X-ray beamline BL5U began in January 2014. An Apple-II type undulator, with a period length of 60 mm and total length of about 2.5 m, was selected for the new beamline. The photon energy range from 20 eV to 200 eV will be covered with the first and higher harmonic radiation. A variable included angle Monk-Gillieson mounting with an entrance slit-less configuration, which is the same as those installed at BL4U and BL6U, has been constructed. Beamline performance tests were carried out in December 2014, and it has been confirmed that the resolving power and photon intensity are very close to the expected values.

For the endstation at BL5U, an experimental setup for spin-resolved photoemission, equipped with a high-resolution hemispherical electron energy analyzer (MBS A-1) with a highly efficient 'VLEED' detector (very low energy electron diffraction), is under continuing development. In pursuit of realizing photoemission experiments with very high spatial resolution, a specially designed post-focusing mirror system is planned to be introduced. It is expected that a small beam spot at the sample position (less than 10 μ m in diameter) will be achieved.

Owing to several serious problems during the construction period of BL5U, the commissioning has been delayed. Accordingly, BL5U will be open to users in the spring of 2016.

In order to promote beamline upgrades and developments of new experimental techniques by users, a new research proposal category, named the "long-term project proposal", was introduced in 2012. The term of validity for this proposal category is three years. Three proposals are currently in progress. Further discussion toward formulating a basic plan on the beamline construction with users will be continued.

All users are required to refer to the beamline manuals and the UVSOR guidebook (the latest revision in PDF format uploaded on the UVSOR web site in June 2010), on the occasion of conducting the actual experimental procedures. Those wishing to use the open and in-house beamlines are recommended to contact the appropriate beamline master (see next page). For updated information on UVSOR, please see http://www.uvsor.ims.ac.jp.

Beamlines at UVSOR

Beamline	Monochromator / Spectrometer	Energy Range	Targets	Techniques	Contact
BL1U	Free electron laser	1.6 - 13.9 eV			M. Katoh mkatoh@ims.ac.jp
BL1B	Martin-Puplett FT-FIR	0.5 - 30 meV	Solid	Reflection Absorption	F. Teshima tetsu@ims.ac.jp
BL2A	Double crystal	585 eV - 4 keV	Solid	Reflection Absorption	N. Kondo nkondo@ims.ac.jp
BL2B	18-m spherical grating (Dragon)	24 - 205 eV	Gas	Photoionization Photodissociation	S. Kera kera@ims.ac.jp
BL3U*	Varied-line-spacing plane grating (Monk-Gillieson)	60 - 800 eV	Gas Liquid Solid	Absorption Photoemission Photon-emission	N. Kosugi kosugi@ims.ac.jp
BL3B	2.5-m off-plane Eagle	1.7 - 30 eV	Solid	Reflection Absorption	M. Hasumoto hasumoto@ims.ac.jp
BL4U	Varied-line-spacing plane grating (Monk-Gillieson)	130 - 700 eV	Gas Liquid Solid	Absorption (Microscopy)	T. Ohigashi ohigashi@ims.ac.jp
BL4B	Varied-line-spacing plane grating (Monk-Gillieson)	25 eV - 1 keV	Gas Solid	Photoionization Photodissociation Photoemission	E. Shigemasa sigemasa@ims.ac.jp
BL5U	Varied-line-spacing plane grating (Monk-Gillieson)	20 - 200 eV	Solid	Photoemission	M. Sakai sakai@ims.ac.jp
BL5B	Plane grating	6 - 600 eV	Solid	Calibration Absorption	M. Hasumoto hasumoto@ims.ac.jp
BL6U [*]	Variable-included-angle varied-line-spacing plane grating	30 - 500 eV	Gas Solid	Photoionization Photodissociation Photoemission	E. Shigemasa sigemasa@ims.ac.jp
BL6B	Michelson FT-IR	3 meV - 2.5 eV	Solid	Reflection Absorption	F. Teshima tetsu@ims.ac.jp
BL7U	10-m normal incidence (modified Wadsworth)	6 - 40 eV	Solid	Photoemission	M. Matsunami matunami@ims.ac.jp
BL7B	3-m normal incidence	1.2 - 25 eV	Solid	Reflection Absorption	M. Hasumoto hasumoto@ims.ac.jp
BL8B	Plane grating	1.9 - 150 eV	Solid	Photoemission	S. Kera kera@ims.ac.jp

Yellow columns represent undulator beamlines. * In-house beamline. *Spherical grating monochromator with translating and rotating assembly including normal incidence mount.

BL1U Light Source Development Station

▼ Description

BL1U has being constructed for developments and applications of various photon sources including free electron laser in the range from visible to deep UV, coherent harmonic generation in the deep UV and VUV, laser Compton scattering gamma-rays and undulator radiation with various polarization properties including optical vortices.

The beam-line is equipped with a dedicated twin polarization variable undulator system with a buncher section, which can be used for a FEL oscillator and a VUV CHG. It is also equipped with a femto-second laser system synchronized with the accelerator, which is used for CHG, slicing, LCS and coherent THz radiation generation.

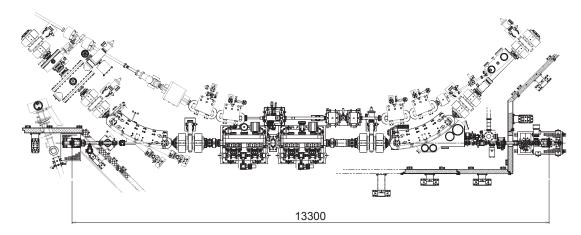


Fig. 1. Configuration of the free electron laser (under reconstruction).



Fig. 2. Twin Apple-II Undulator.

Fig. 3. Accelerator synchronized Laser System.

▼ Technical Data of FEL

Wave Length	199-800 nm
Spectral Band Width	~10 ⁻⁴
Polarization	Circular/Linear
Pulse Rate	11.26 MHz
Max. Ave. Power	~1W

Technical Data of Ti:Sa Laser			
Wave Length	800 nm		
Pulse Length	130 fsec		
Oscillator	90.1 MHz		
Pulse Energy	2.5mJ 10mJ 50mJ		
Repetition Rate	1kHz 1kHz 10Hz		

BL1B Terahertz Spectroscopy Using Coherent Synchrotron Radiation

▼Description

Coherent synchrotron radiation (CSR) is a powerful light source in the terahertz (THz) region. This beamline has been constructed for basic studies on the properties of THz-CSR. However, it can be also used for measurements of reflectivity and transmission spectra of solids using conventional synchrotron radiation.

The emitted THz light is collected by a three-dimensional magic mirror (3D-MM, M0) of the same type as those already successfully installed at BL43IR in SPring-8 and BL6B in UVSOR-II. The 3D-MM was installed in bending-magnet chamber #1 and is controlled by a 5-axis pulse motor stage (x, z translation; θ_x , θ_y , θ_z rotation). The acceptance angle was set at 17.5-34 degrees (total 288 mrad) in the horizontal direction. The vertical angle was set at ± 40 mrad to collect the widely expanded THz-CSR.

The beamline is equipped with a Martin-Puplett type interferometer (JASCO FARIS-1) to cover the THz spectral region from 4 to 240 cm⁻¹ ($hv = 500 \mu eV-30 meV$). There is a reflection/absorption spectroscopy (RAS) end-station for large samples (~ several mm). At the RAS end-station, a liquid-helium-flow type cryostat with a minimum temperature of 4 K is installed.

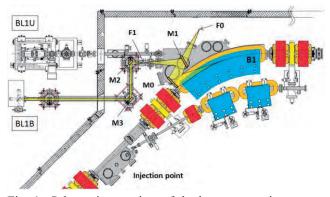


Fig. 1. Schematic top view of the beam extraction part BL1B. of the THz-CSR beamline, The three-dimensional magic mirror (3D-MM, M0) and a plane mirror (M1) are located in the bending-magnet chamber. A parabolic mirror (M2) is installed to form a parallel beam. The straight section (BL1U) is used for coherent harmonic generation (CHG) in the VUV region.

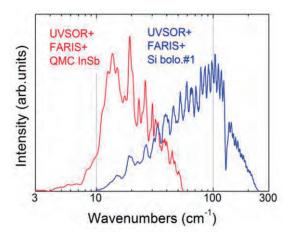


Fig. 2. Obtained intensity spectra with the combination of a light source (UVSOR), interferometer (FARIS-1), and detectors (Si bolometer and InSb hot-electron bolometer).

•	Technical Data	
	Interferometer	Martin-Puplett (JASCO FARIS-1)
	Wavenumber range	$4-240 \text{ cm}^{-1}$
	(Energy range)	(500 µeV-30 meV)
	Resolution in cm ⁻¹	0.25 cm ⁻¹
	Experiments	Reflection/transmission spectroscopy
	Miscellaneous	Users can use their experimental system in this beamline.

BL2A Soft X-Ray Beamline for Photoabsorption Spectroscopy

▼Description

BL2A, which was moved its previous location as BL1A in 2011, is a soft X-ray beamline for photoabsorption spectroscopy. The beamline is equipped with a focusing premirror and a double-crystal monochromator [1]. The monochromator serves soft X-rays in the energy region from 585 to 4000 eV using several types of single crystals, such as β -Al₂O₃, beryl, KTP (KTiOPO₄), quartz, InSb, and Ge. The throughput spectra measured using a Si photodiode (AXUV-100, IRD Inc.) are shown in Fig. 1. The typical energy resolution ($E / \Delta E$) of the monochromator is approximately 1500 for beryl and InSb.

A small vacuum chamber equipped with an electron multiplier (EM) detector is available. Photoabsorption spectra for powdery samples are usually measured in total electron yield mode, with the use of the EM detector. A silicon drift detector is also available for measuring partial fluorescence yields from solid samples.

[1] Hiraya et al., Rev. Sci. Instrum. 63 (1992) 1264.

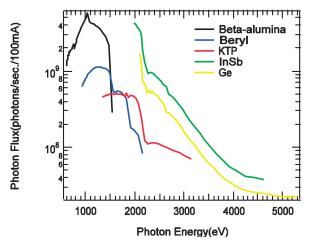


Fig. 1. hroughput spectra of the double-crystal monochromator at BL2A.



Fig. 2. Side view of BL2A.

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V ICCIIIICAI Data		
Monochromator	Double crystal monochromator	
Monochromator crystals:	β -Al ₂ O ₃ (22.53 Å, 585–1609 eV), beryl (15.965 Å, 826–2271 eV),	
(2d value, energy range)	KTP (10.95 Å, 1205–3310 eV), quartz (8.512 Å, 1550–4000 eV),	
	InSb (7.481 Å, 1764–4000 eV), Ge (6.532 Å, 2094–4000 eV)	
Resolution	$E / \Delta E = 1500$ for beryl and InSb	
Experiments	Photoabsorption spectroscopy (total electron yield using EM and partial	
	fluorescence yield using SDD)	

BL2B Photoelectron Spectroscopy of Molecular Solids

Description

This beamline previously dedicated for experiments in the field of gas phase photoionization and reaction dynamics. Then, the beamline has been reconstructed for photoelectron spectroscopy of molecular solids with a new end station, and experiments can be performed from May 2014. The monochromator is a spherical grating Dragon type with 18-m focal length. High throughput $(1 \times 10^{10} \text{ photons s}^{-1})$ and high resolution ($E / \Delta E = 2000 - 8000$) are achieved simultaneously under the condition of the ring current of 100 mA [1]. The optical system consists of two pre-focusing mirrors, an entrance slit, three spherical gratings (G1 - G3), two folding mirrors, a movable exit slit, and a refocusing mirror [2]. The monochromator is designed to cover the energy range of 23–205 eV with the three gratings: G1 (2400 lines mm⁻¹, R = 18 m) at 80–205 eV; G2 (1200 lines mm⁻¹, R = 18 m) at 40–100 eV; G3 (2400 lines mm⁻¹, R = 9.25 m) at 23–50 eV. The percentage of the second-order light contamination at hv = 45.6 eV is 23% for G2 or 7% for G3.

A UHV chamber is placed downstream of the refocusing mirror chamber and equipped silicon photodiode, sapphire plate Au mesh and filters for absolute photon flux measurement, monitor the photon-beam position, relative photon flux measurements and attenuate higher order light, respectively.

The new end station consists of a main chamber with a hemispherical analyzer (SCIENTA R3000) and a liquid-He-cooled cryostat (temperature range of 15-400 K) with 5-axis stage, a sample preparation chamber with a fast-entry load-lock chamber and a cleaning chamber with LEED, ion gun for sputtering and IR heating unit.

M. Ono, H. Yoshida, H. Hattori and K. Mitsuke, Nucl. Instrum. Meth. Phys. Res. A 467-468 (2001) 577.
H. Yoshida and K. Mitsuke, J. Synchrotron Radiation 5 (1998) 774.



Fig. 1. 18 m spherical grating monochromator at BL2B.

Fig. 2. End station of BL2B for photoelectron spectroscopy of molecular solids.

v Teenmeur D'utu	
Monochromator	18 m spherical grating Dragon-type
Wavelength Range	23-205 eV
Resolution	2000–8000 depending on the gratings
Experiments	Angle-resolved ultraviolet photoemission spectroscopy

BL3U Varied-Line-Spacing Plane Grating Monochromator for Molecular Soft X-Ray Spectroscopy

▼ Description

The beamline BL3U is equipped with an in-vacuum undulator composed of 50 periods of 3.8 cm period length. The emitted photons are monochromatized by the varied-line-spacing plane grating monochromator (VLS-PGM) designed for various spectroscopic investigations in the soft X-ray range including soft X-ray emission studies. Three holographically ruled laminar profile plane gratings are designed to cover the photon energy range from 60 to 800 eV. The beamline has two endstations, namely, XES setup and multi-purpose setup. The XES setup is used for soft X-ray emission spectroscopy. The beam is horizontally focused onto the sample position by a plane-elliptical mirror, M2X. In the multi-purpose setup, the beam is focused by the toroidal mirror M2. Between the sample position and M2, the differential pumping is placed. XAS of liquid samples and the application of in operando observations are performed at the experimental stage of the multi-purpose setup.

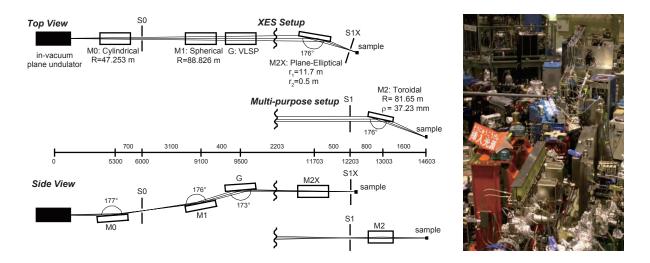


Fig. 1. Schematic layout (left) and the photography (right) of the BL3U. The distances along the beam from the center of the in-vacuum plane undulator are shown in millimeters. S1X and M2X can be replaced with the other exit slit S1 so that experiments can be carried out at either the XES or the multipurpose endstation. In the XES setup, the sample is placed 5–10 mm downstream of S1X.

▼ Technical Data	
Monochromator	Varied-line-spacing plane grating monochromator
Energy Range	60-800 eV
Resolution	$E / \Delta E > 10\ 000$
Experiments	Soft X-ray spectroscopy (XPS, XES, XAS)
Beam Size	Gaussian shape
(XES Endstation)	Vertical 5-20 µm; Horizontal 41 µm (FWHM)

BL3B (HOTRLU) VIS-VUV Photoluminescence and Reflection/Absorption Spectroscopy

▼ Description

BL3B has been constructed to study photoluminescence (PL) in the visible (VIS) to vacuum ultraviolet (VUV) region. This beamline consists of a 2.5 m off-plane Eagle type normal-incidence monochromator, which covers the VUV, UV, and VIS regions, i.e., the energy (wavelength) region of 1.7-31 eV (40-730 nm), with three spherical gratings having constant grooving densities of 1200, 600, and 300 l/mm optimized at the photon energies of ~20, ~16, and ~6 eV, respectively. The schematic side view and top view layouts are shown in Figs. 1(a) and 1(b), respectively. The FWHM of the beam spot at the sample position is 0.25 mm (V) × 0.75 mm (H). Low energy pass filters (LiF, quartz, WG32, OG53) can be inserted automatically to maintain the optical purity in the G3 (300 l/mm) grating region (1.7~11.8 eV). Figure 2 shows the throughput spectra (photon numbers at a beam current of 300 mA) for each grating with entrance and exit slit openings of 0.1 mm (resolving power $E / \Delta E$ of ~2000 (G3, ~6.8 eV)). Since both slits can be opened up to 0.5 mm, a monochromatized photon flux of 10^{10} photons/s or higher is available for PL measurements in the whole energy region.

The end station is equipped with a liquid-helium-flow type cryostat for sample cooling and two detectors; one of which is a photomultiplier with sodium salicylate and the other a Si photodiode for reflection/absorption measurement. For the PL measurements in the wide energy region from VIS to VUV, two PL monochromators, comprising not only a conventional VIS monochromator but also a VUV monochromator with a CCD detector, are installed at the end station.

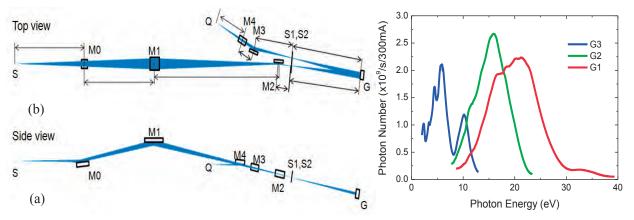


Fig. 1. Schematic layout of the BL3B (a) side view and (b) top view.

• Technical Data	
Monochromator	-2.5 m normal-incidence monochromator
Energy range	1.7-31 eV (40~730 nm)
Resolution ($\Delta h\nu / h\nu$)	≥ 12000 (at ~ 6.9 eV, 0.02 mm slits, G1 (1200 l/mm)
Experiments	Photoluminescence, reflection, and absorption spectroscopy, mainly for solids

BL4U Scanning Transmission X-Ray Microscopy in the Soft X-Ray Region

Description

In the soft x-ray region, there are several absorption edges of light elements and transition metals. The near edge X-ray absorption fine structure (NEXAFS) brings detailed information about the chemical state of target elements. A scanning transmission X-ray microscope (STXM) in the soft X-ray region is a kind of extended technique of the NEXAFS with high spatial resolution. The STXM has a capability of several additional options, for example, in-situ observations, 3-dimensional observation by computed tomography and ptychography, by utilizing the characteristics of the X-rays. The STXM can be applied to several sciences, such as polymer science, material science, cell biology, environmental science, and so on.

This beamline equips an in-vacuum undulator, a varied-line-spacing plane grating monochromator and a fixed exit slit. The soft X-ray energy range from 130 to 770 eV with the resolving power (E / Δ E) of 6,000 is available. The aperture size of the fixed exit slit determines not only the resolving power but also the size of a microprobe. A Fresnel zone plate is used as a focusing optical device through an order select aperture and its focal spot size of ~30 nm is available at minimum. An image is acquired by detecting intensities of the transmitted X-rays by a photomultiplier tube with scintillator with scanning a sample 2-dimensionally. By changing the energy of the incident beam, each 2-dimensional NEXAFS image is stacked. A main chamber of STXM is separated from the beamline optics by a silicon nitride membrane of 100-nm thickness; therefore, sample folders can be handled in vacuum or in helium.

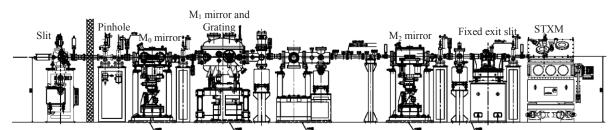


Fig. 1. Schematic image of BL4U.

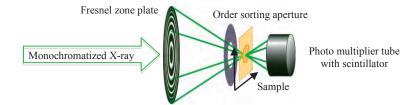


Fig. 2. Schematic image of the STXM.

V Technical Data	
Energy range (E)	130 -770 eV
Resolving power (E / Δ E)	~6000
Focusing optical element	Fresnel zone plate
Spatial resolution	~30 nm
Experiments	2-dimensinal absorption spectroscopy
Measurement environment	standard sample folder in vacuum or in helium,
	specially designed sample cell in ambient condition

BL4B Varied-Line-Spacing Plane Grating Monochromator for Molecular Soft X-Ray Spectroscopy

▼ Description

The beamline BL4B equipped with a varied-line-spacing plane grating monochromator (VLS-PGM) was constructed for various spectroscopic investigations in a gas phase and/or on solids in the soft X-ray range. Three holographically ruled laminar profile plane gratings with SiO₂ substrates are designed to cover the photon energy range from 25 to 800 eV. The gratings with groove densities of 100, 267, and 800 l/mm cover the spectral ranges of 25–100, 60–300, and 200-1000 eV, respectively, and are interchangeable without breaking the vacuum. Figure 1 shows the absolute photon flux for each grating measured using a Si photodiode (IRD Inc.), with the entrance- and exit-slit openings set at 50 and 50 μ m, respectively. The maximum resolving power (*E* / ΔE) achieved for each grating exceeds 5000.

There is no fixed endstation on this beamline. A small vacuum chamber equipped with an electron multiplier (EM) detector is available. Soft X-ray absorption spectra of solid samples are usually measured by means of the total electron yield method using EM, and the partial fluorescence yield method using a silicon drift detector (SDD).

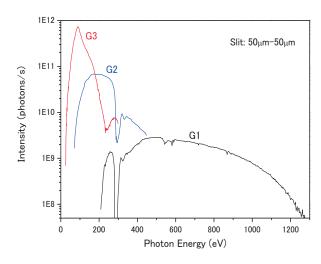


Fig. 1. Throughput from the VLS-PGM monochromator on BL4B.



Fig. 2. Photo of BL4B.

Monochromator	Varied-line-spacing Plane Grating Monochromator
Energy range	25-1000 eV
Resolution	$E / \Delta E > 5000$ (at maximum)
Experiments	Soft X-ray spectroscopy (mainly, photoabsorption spectroscopy for solid targets
	by means of total electron yield method using EM and partial fluorescence yield
	method using SDD)

BL5U Photoemission Spectroscopy of Solids and Surfaces

▼Description

This beamline was originally used for angle-resolved photoemission spectroscopy (ARPES) study of solids and surfaces. After Jan 2014, the beamline has been shutdown for upgrade. The whole beamline, including the undulator and the endstation, will be renewed to perform higher energy resolution ARPES experiments. This beamline will also have new capability to obtain spin- and spatial-dependence of the electronic structure of solids using new spin detector and micro-focused beam. This beamline will be open for users from FY2016.

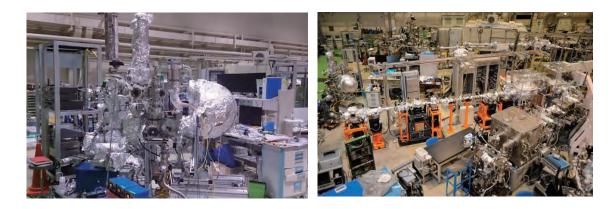


Fig. 1. Pictures of BL5U on May 2014.

Monochromator	Monk-Gillieson VLS-PGM
Energy Range	20-200 eV
Resolution	$h\nu/\Delta E > 10,000$ for $< 10 \ \mu m$ slits
Experiment	ARPES, Spin-resolved ARPES, Space-resolved ARPES
Flux	${<}10^{12}$ photons/s for ${<}10~\mu m$ slits (at the sample position)
Beam spot size	400 (H) x 5-20 (V) μm, 10 (H) x 4-6 (V) μm (microscope)
Main Instruments	Hemispherical photoelectron analyzer (MBS A-1), Liq-He flow cryostat with
	5-axis manipulator (5-400 K)

▼ Technical Data (Expected Performance)

BL5B Calibration Apparatus for Optical Elements and Detectors

▼ Description

BL5B has been constructed to perform calibration measurements for optical elements and detectors. This beamline is composed of a plane grating monochromator (PGM) and three endstations in tandem. The most upstream station is used for the calibration measurements of optical elements, the middle one for optical measurements for solids, and the last for photo-stimulated desorption experiments. The experimental chamber at the most downstream station is sometimes changed to a chamber for photoemission spectroscopy. The calibration chamber shown in Fig. 2 is equipped with a goniometer for the characterization of optical elements, which has six degrees of freedom, X-Y translation of a sample, and interchanging of samples and filters. These are driven by pulse motors in vacuum. Because the polarization of synchrotron radiation is essential for such measurements, the rotation axis can be made in either the horizontal or vertical direction (s- or p-polarization).

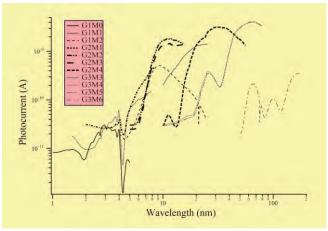




Fig. 1. Throughput spectra for possible combinations of gratings and mirrors at BL5B measured by a gold mesh.

Fig. 2. A side view of the experimental chamber for calibration measurements.

Monochromator	Plane Grating Monochromator
Energy range	6-600 eV (2-200 nm)
Resolution	$E / \Delta E \sim 500$
Experiments	Calibration of optical elements, reflection and absorption spectroscopy
	mainly for solids

BL6U Variable-Included-Angle VLS-PGM for Molecular Soft X-Ray Spectroscopy

▼ Description

The beamline BL6U equipped with a variable-included-angle Monk-Gillieson mounting monochromator with a varied-line-spacing plane grating was constructed for various spectroscopic investigations requiring high-brilliance soft X-rays in a gas phase and/or on solids. Through a combination of undulator radiation and sophisticated monochromator design (entrance slit-less configuration and variable-included-angle mechanism), using a single grating, the monochromator can cover the photon energy ranging from 30 to 500 eV, with resolving power of greater than 10000 and photon flux of more than 10^{10} photons/s. Figure 1 shows an example of the monochromator throughput spectra measured using a Si photodiode, with the exit-slit opening set at 30 μ m, which corresponds to the theoretical resolving power of 10000 at 80 eV.

There is no fixed endstation on this beamline.

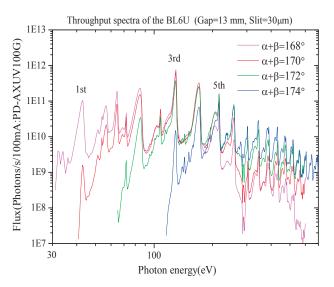


Fig. 1. Throughput spectra of the BL6U monochromator at various included angles.



Fig. 2. Photo of BL6U.

Monochromator	Variable-included-angle Varied-line-spacing Plane Grating	
	Monochromator	
Energy range	40-500 eV	
Resolution	$E / \Delta E > 10000$ (at maximum)	
Experiments	High-resolution soft X-ray spectroscopy (mainly photoelectron	
	spectroscopy for gaseous and solid targets)	

BL6B Infrared and Terahertz Spectroscopy of Solids

Description

Synchrotron radiation (SR) has good performance (high brilliance and high flux) not only in the VUV and soft X-ray (SX) regions but also in the infrared (IR) and THz regions. BL6B covers the IR and THz regions. The previous beamline, BL6A1, which was constructed in 1985, was the pioneer in IRSR research. The beamline was deactivated at the end of FY2003 and a new IR/THz beamline, BL6B (IR), was constructed in FY2004. The front-end part including bending duct #6 was replaced with a new part having a higher acceptance angle (215 $(H) \times 80$ (V) mrad²) using a magic mirror, as shown in Fig. 1.

There are two Michelson type interferometers in this endstation; with first one (Bruker Vertex70v), which covers a wide spectral region from 30 to 20,000 cm⁻¹ (hv = 4 meV-2.5 eV), reflection/absorption spectroscopy measurements of large samples (up to several mm) and IR/THz microscopy measurements of tiny samples (up to several tens of μ m) can be performed. For reflection/absorption spectroscopy measurements, a liquid-helium-flow type cryostat with a minimum temperature of 4 K is installed. The other interferometer (Jasco FT/IR-6100), which covers 350 to 15,000 cm⁻¹ (hv = 45 meV-1.8 eV), has been available for IR microscopy imaging measurements from FY2014. One can also perform ATR measurements using diamond ATR prism.

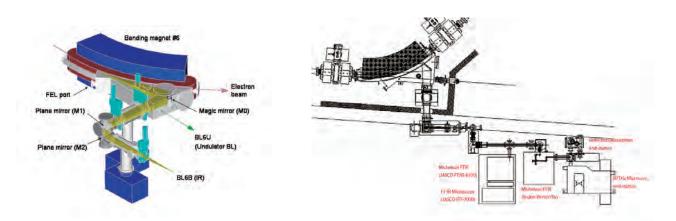


Fig. 1. Design of the optics and front end of BL6B. Fig. 2. Schematic top view of BL6B.

V Itennical Data		
Interferometer	Michelson (Bruker Vertex70v)	Michelson (Jasco FT/IR-6100)
Wavenumber Range	30-20,000 cm ⁻¹	350-15,000 cm ⁻¹
(Energy range)	(4 meV-2.5 eV)	(45 meV-1.8 eV)
Resolution in cm ⁻¹	0.1 cm ⁻¹	0.5 cm^{-1}
Experiments	Reflectivity and transmission spectroscopy THz Microspectroscopy	IR microscopy imaging (JASCO IRT-7000) ATR spectroscopy

BL7U (SAMRAI) Angle-Resolved Photoemission of Solids in the VUV Region

▼ Description

Beamline 7U, named the Symmetry- And Momentum-Resolved electronic structure Analysis Instrument (SAMRAI) for functional materials, was constructed to provide a photon flux with high energy resolution and high flux mainly for high-resolution angle-resolved photoemission spectroscopy of solids [1]. An APPLE-II-type variable-polarization undulator is installed as the light source. The undulator can produce intense VUV light with horizontal/vertical linear and right/left circular polarization. The undulator light is monochromatized by a modified Wadsworth type monochromator with three gratings (10 m radius; 1200, 2400, and 3600 lines/mm optimized at hv = 10, 20, and 33 eV). The energy resolution of the light ($hv / \Delta hv$) is more than 10^4 with a photon flux of 10^{11} - 10^{12} ph/s or higher on samples in the entire energy region.

The beamline has a photoemission end-station equipped with a 200 mm-radius hemispherical photoelectron analyzer (MB Scientific AB, A-l analyzer) with a wide-angle electron lens and a liquid-helium-cooled cryostat with 6-axis pulse motor control (AVC Co., Ltd., i-GONIO). The main function of the beamline is to determine the three-dimensional Fermi surface and electronic structure of solids at low temperatures and their temperature dependence in order to reveal the origin of their physical properties.

[1] S. Kimura, T. Ito, M. Sakai, E. Nakamura, N. Kondo, K. Hayashi, T. Horigome, M. Hosaka, M. Katoh, T. Goto, T. Ejima and K. Soda, "SAMRAI: A variably polarized angle-resolved photoemission beamline in the VUV region at UVSOR-II," Rev. Sci. Instrum. **81** (2010) 053104.

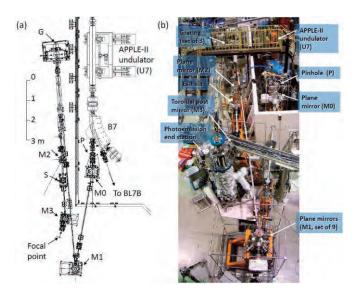


Fig. 1. Layout (a) and photograph (b) of the SAMRAI beamline consisting of an APPLE-II type undulator (U7), a modified Wadsworth type monochromator (M0-S), and а high-resolution photoemission analyzer at the focal point. The monochromator has five major optical components: two plane mirrors (M0 and M1) with water cooling, one set of three spherical gratings (G), an exit slit (S), and one toroidal refocusing mirror (M3). The spherical gratings have a radius of 10 m and are located 22 m from the center of the undulator. There is no entrance slit. S is located 6.47 m from G. A second branch for a VUV microscope end-station is planned to be constructed after the plane mirror (M2) located between G and S.

Light source	APPLE-II type undulator ($\lambda_u = 76 \text{ mm}, N = 36$)
	vertical/horizontal linear, right/left circular
Monochromator	10 m normal-incidence monochromator (modified Wadsworth type)
Photon energy range	6-40 eV ($\lambda = 30 \sim 200$ nm)
Resolution $(hv / \Delta hv)$	1×10^{4} - 5×10^{4}
Photon flux on sample	$\geq 10^{12}$ -10 ¹¹ ph/s (depending on $h\nu$)
Beam size on sample	$200 (H) \times 50 (V) \mu m^2$
Experiments	Angle-resolved photoemission of solids
-	(MB Scientific A-1 analyzer, acceptance angle: ± 18 deg)

BL7B 3 m Normal-Incidence Monochromator for Solid-State Spectroscopy

Description

BL7B has been constructed to provide sufficiently high resolution for conventional solid-state spectroscopy, sufficient intensity for luminescence measurements, wide wavelength coverage for Kramers–Kronig analyses, and minimum deformation to the polarization characteristic of incident synchrotron radiation. This beamline consists of a 3-m normal incidence monochromator, which covers the vacuum ultraviolet, ultraviolet, visible, and infrared, i.e., the wavelength region of 50–1000 nm, with three gratings (1200, 600, and 300 l/mm). Two interchangeable refocusing mirrors provide two different focusing positions. For the mirror with the longer focal length, an LiF or a MgF₂ window valve can be installed between the end valve of the beamline and the focusing position. Figure 1 shows the absolute photon intensity for each grating with the entrance and exit slit openings of 0.5 mm. A silicon photodiode (AXUV-100, IRD Inc.) was utilized to measure the photon intensity and the absolute photon flux was estimated, taking the quantum efficiency of the photodiode into account.

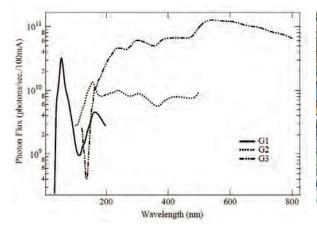




Fig. 1. Throughput spectra of BL7B measured using Fig. a silicon photodiode.

Fig. 2. Photo of BL7B.

Monochromator	3 m Normal-Incidence Monochromator
Wavelength Range	1.5-25 eV (50-1000 nm)
Resolution	$E / \Delta E = 4000-8000$ for 0.01 mm slits
Experiments	Absorption, reflection, and fluorescence spectroscopy, mainly for solids

BL8B Angle-Resolved Ultraviolet Photoelectron Spectrometer for Solids

▼Description

BL8B is a beamline for the angle-resolved ultraviolet photoemission spectroscopy (ARUPS) system, which is designed to measure various organic solids such as molecular crystals, organic semiconductors, and conducting polymers. This beamline consists of a plane-grating monochromator (PGM), a sample preparation chamber with a fast-entry load-lock chamber, a measurement chamber (base pressure 1×10^{-10} Torr), a cleaning chamber (base pressure 1×10^{-10} Torr), and a sample evaporation chamber (base pressure 3×10^{-10} Torr). The cleaning chamber is equipped with a back-view LEED/AUGER, an ion gun for Ar⁺ sputtering, and an infrared heating unit. The PGM consists of premirrors, a plane grating, focusing mirror, and a post-mirror, with an exit slit. It covers the wide range from 2 to 130 eV with two exchanging gratings (G1: 1200 l/mm, G2: 450 l/mm) and five cylindrical mirrors. The toroidal mirror focuses the divergent radiation onto the sample in the measurement chamber. The spot size of the zeroth-order visible light at the sample surface is approximately $1 \times 1 \text{ mm}^2$. Figure 1 shows the throughput spectra of PGM (slit = 100 µm). The energy resolution at a slit width of 100 µm was found to be $E / \Delta E = 1000$ in the wavelength range from 2 to 130 eV. A hemispherical electron energy analyzer of 75 mm mean radius with an angular resolution less than 2° can be rotated around the vertical and horizontal axes.

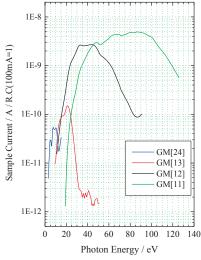


Fig. 1. Throughput spectra of plane-grating monochromator at BL8B (slit = $100 \mu m$).

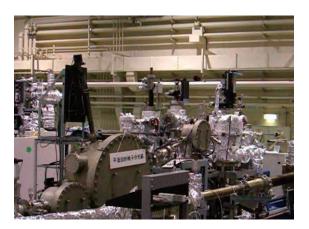


Fig. 2. A photo of BL8B.

Monochromator	Plane-grating monochromator
Wavelength Range	9-600 nm
Resolution	$E / \Delta E = 1000$
Experiments	Angle-resolved ultraviolet photoemission spectroscopy

UVSOR User 2

